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ISSUE DATE

U.S. UTILITY Patent Application

01/18/2002  
 10050896  
 204  
 271  
 1753  
 WONG, E

APPL NUM 10050896	FILING DATE 01/18/2002	CLASS 204	SUBCLASS 271	GAU 1753	EXAMINER WONG, E
<b>**APPLICANTS:</b> Colombier Gabriel; Safrany Jean-Sylvestre; Loreau Bernard; Tournier Sandrine;					
<b>**CONTINUING DATA VERIFIED:</b> This application is a CIP of PCT/FR00/02061 07/18/2000					
<b>** FOREIGN APPLICATIONS VERIFIED:</b> FRANCE 99/09690 07/22/1999					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed: <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials				ATTORNEY DOCKET NO 02006CIP	
TITLE : Continuous nickel plating process for an aluminum conductor and corresponding device					

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Assistant Examiner	
<b>ISSUE FEE</b>		Total Claims	Print Claim for O.G.
Amount Due	Date Paid	<b>DRAWING</b>	
		Sheets Drwg.	Figs. Drwg.
		Print Fig.	
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		Primary Examiner	
		PREPARED FOR ISSUE	
		Application Examiner	
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